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Supporting Information

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Sequentially PVD-Grown Indium and Gallium Selenides Under Compositional and Layer Thickness Variation: Preparation, Structural and Optical Characterization

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Supplementary

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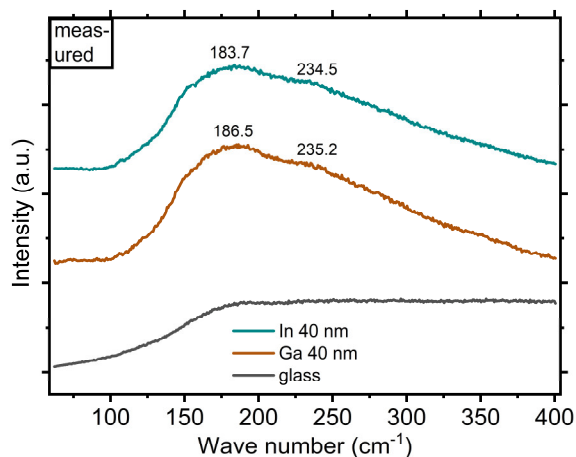


Figure S1: Measured Raman spectra of pure In, Ga, and glass.

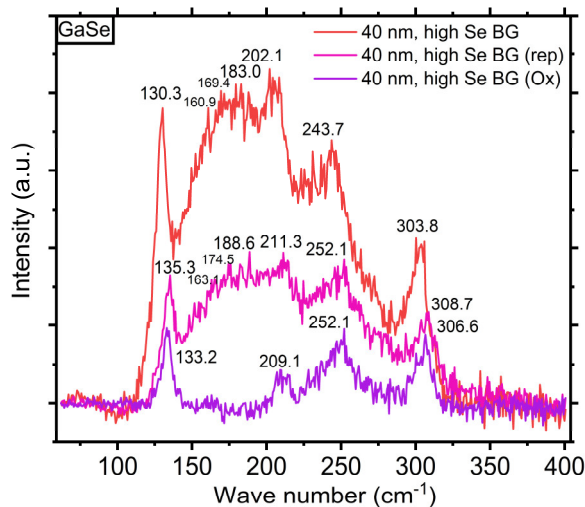


Figure S2: Measured Raman spectra of GaSe (prepared by chalcogenization in high Se background of a 40 nm Ga precursor film) immediately after preparation, after being exposed to air during the various measurements (rep) or for three days (Ox).

Table S1: Overview of XRD-database files from where the peak lines representing different compounds and phases of In-Se in Figure 3 were extracted.

COD: Crystallography Open Database (<http://www.crystallography.net>)

SD: Springer Materials (for In_4Se_3 https://materials.springer.com/isp/crystallographic/docs/sd_0451600)

	chemical formula	Data base no
150 nm, 0.2 g Se	$\gamma\text{-In}_2\text{Se}_3$	COD_2106380
150 nm, 0.1 g Se	$\gamma\text{-In}_2\text{Se}_3$	COD_2106380
150 nm, high Se BG	$\beta\text{-}\gamma\text{-InSe}$; In_4Se_3	COD_9008967/ COD_1534648 ; SD_0451600
150 nm, low Se BG	$\alpha\text{-}\beta\text{-In}_2\text{O}_3$; In	COD_9015718 ; COD_1512513
100 nm, 0.2 g Se	$\gamma\text{-In}_2\text{Se}_3$	COD_2106380
100 nm, 0.1 g Se	$\gamma\text{-In}_2\text{Se}_3$	COD_2106380
100 nm, high Se BG	$\beta\text{-}\gamma\text{-InSe}$	COD_9008967/ COD_1534648
100 nm, low Se BG	$\beta\text{-}\gamma\text{-InSe}$; $\alpha\text{-}\beta\text{-In}_2\text{O}_3$	COD_9008967/ COD_1534648 ; COD_9015718
40 nm, high Se BG	$\gamma\text{-In}_2\text{Se}_3$; $\alpha\text{-In}_2\text{Se}_3$	COD_2106380 ; COD_1528775
40 nm, low Se BG	$\gamma\text{-In}_2\text{Se}_3$; $\alpha\text{-In}_2\text{Se}_3$	COD_2106380 ; COD_1528775
20 nm, high Se BG	$\gamma\text{-In}_2\text{Se}_3$; $\alpha\text{-In}_2\text{Se}_3$	COD_2106380 ; COD_1528775
20 nm, low Se BG	$\alpha\text{-In}_2\text{Se}_3$; $\gamma\text{-In}_2\text{Se}_3$	COD_1528775 ; COD_2106380

Table S2: Overview of XRD-database files from where the peak lines representing different compounds and phases of Ga-Se in Figure 4 were extracted.

COD: Crystallography Open Database (<http://www.crystallography.net>)

ICSD: FIZ-Karlsruhe, Leibniz Institute for Information Infrastructure (<http://icsd.fiz-karlsruhe.de>)

	chemical formula	Data base no
150 nm, 0.2 g Se	$\alpha\text{-}\beta\text{-Ga}_2\text{Se}_3$	COD_2020137 / ICSD_35028
150 nm, 0.1 g Se	$\alpha\text{-}\beta\text{-Ga}_2\text{Se}_3$	COD_2020137 / ICSD_35028
150 nm, high Se BG	$\beta\text{-}\gamma\text{-}\delta\text{-}\epsilon\text{-GaSe}$	COD_1530863 / ICSD_73388 / COD_2106698 / COD_2105478
150 nm, low Se BG	$\beta\text{-Ga}_2\text{O}_3$; Ga	COD_2004987 ; COD_8104301
100 nm, 0.2 g Se	$\alpha\text{-}\beta\text{-Ga}_2\text{Se}_3$	COD_2020137 / ICSD_35028
100 nm, 0.1 g Se	$\alpha\text{-}\beta\text{-Ga}_2\text{Se}_3$	COD_2020137 / ICSD_35028
100 nm, high Se BG	$\beta\text{-}\gamma\text{-}\delta\text{-}\epsilon\text{-GaSe}$	COD_1530863 / ICSD_73388 / COD_2106698 / COD_2105478
100 nm, low Se BG	$\beta\text{-Ga}_2\text{O}_3$; $\beta\text{-}\gamma\text{-}\delta\text{-}\epsilon\text{-GaSe}$; Ga	COD_2004987 ; COD_1530863 / ICSD_73388 / COD_2106698 / COD_2105478 ; COD_8104301
40 nm, high Se BG	$\beta\text{-}\gamma\text{-}\delta\text{-}\epsilon\text{-GaSe}$	COD_1530863 / ICSD_73388 / COD_2106698 / COD_2105478
40 nm, low Se BG	$\beta\text{-Ga}_2\text{O}_3$; Ga	COD_2004987 ; COD_8104301
20 nm, high Se BG	$\alpha\text{-}\beta\text{-Ga}_2\text{Se}_3$	COD_2020137 / ICSD_35028
20 nm, low Se BG	Ga ; $\beta\text{-Ga}_2\text{O}_3$	COD_8104301 ; COD_2004987

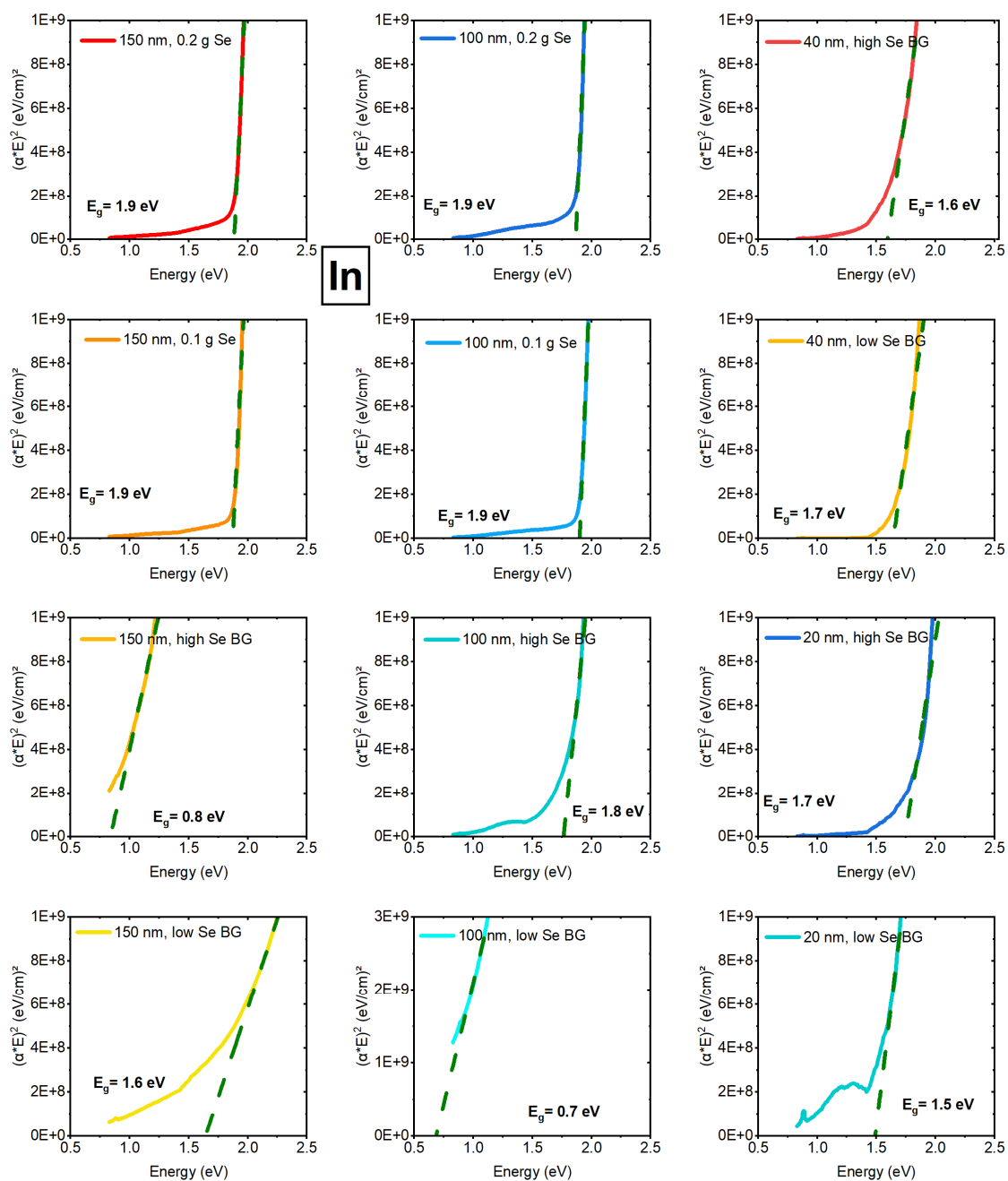


Figure S3: Tauc plot of $(\alpha E)^2$ for potential derivation of direct band gap value from linear fitting; In-Se samples with 150, 100, 40 or 20 nm In precursor thickness and selenized in various Se content (BG = background).

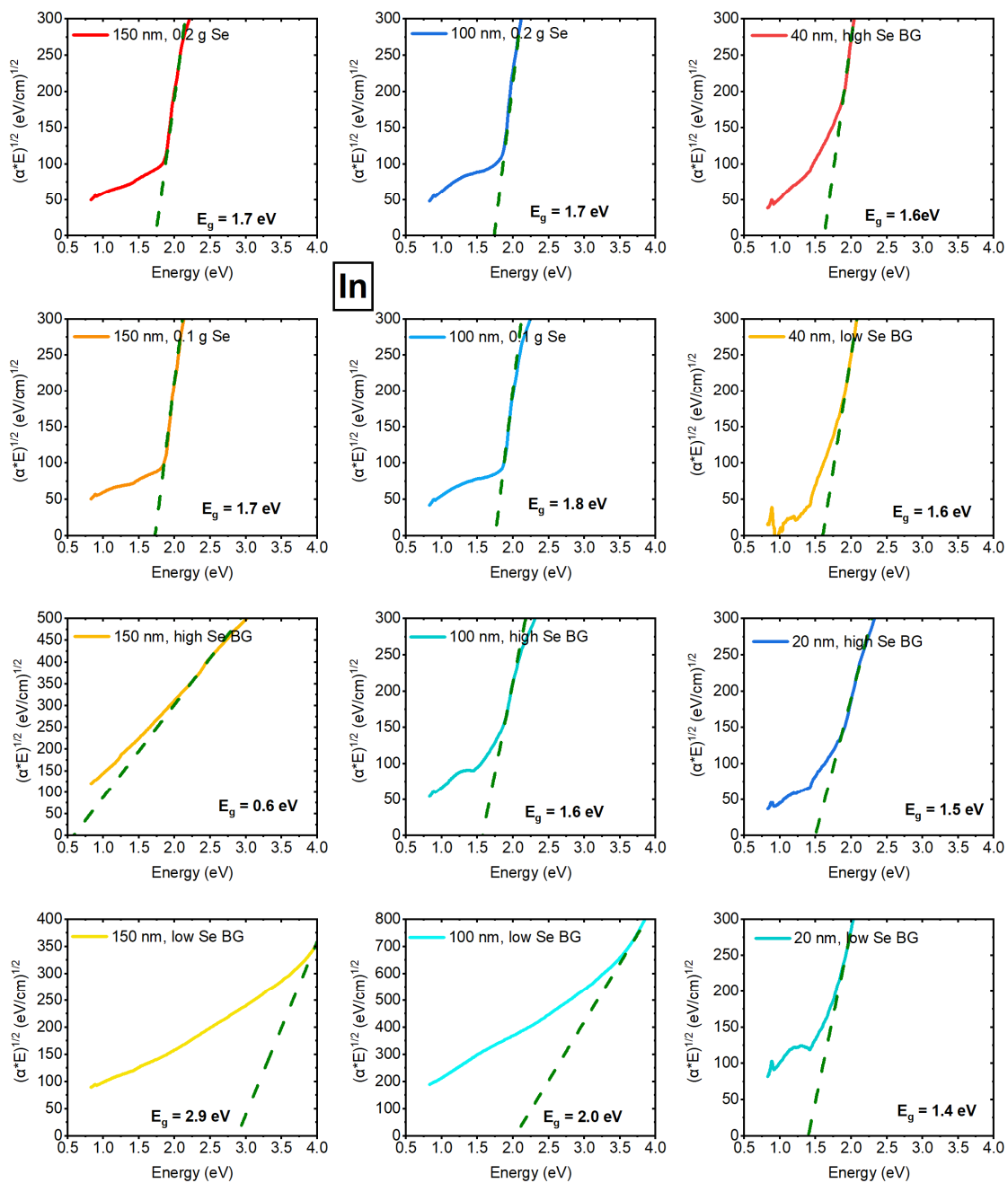


Figure S4: Tauc plot of $(\alpha E)^{1/2}$ for potential derivation of indirect band gap value from linear fitting; In-Se samples with 150, 100, 40 or 20 nm In precursor thickness and selenized in various Se content (BG = background).

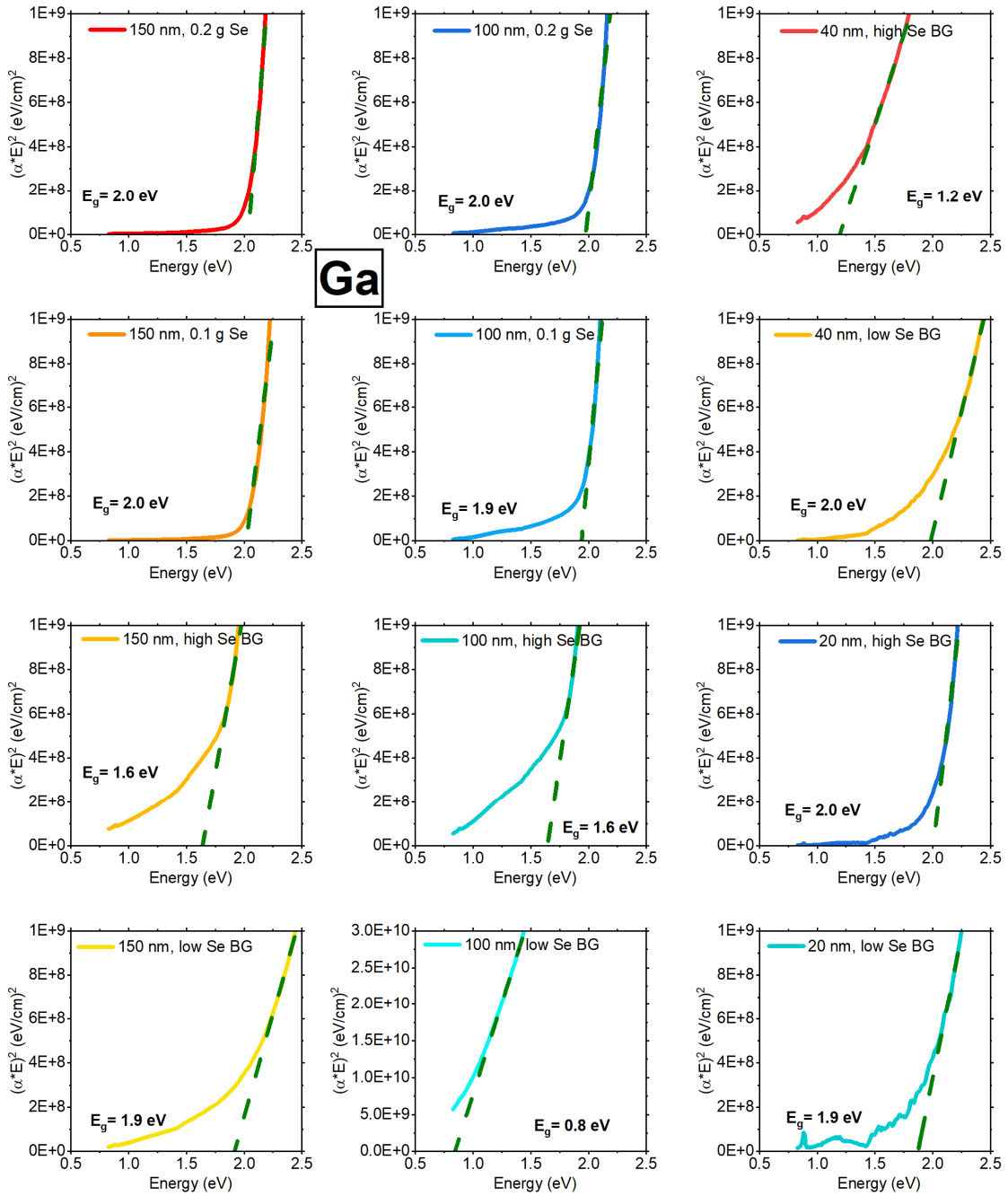


Figure S5: Tauc plot of $(\alpha E)^2$ for potential derivation of direct band gap value from linear fitting; Ga-Se samples with 150, 100, 40 or 20 nm Ga precursor thickness and selenized in various Se content (BG = background).

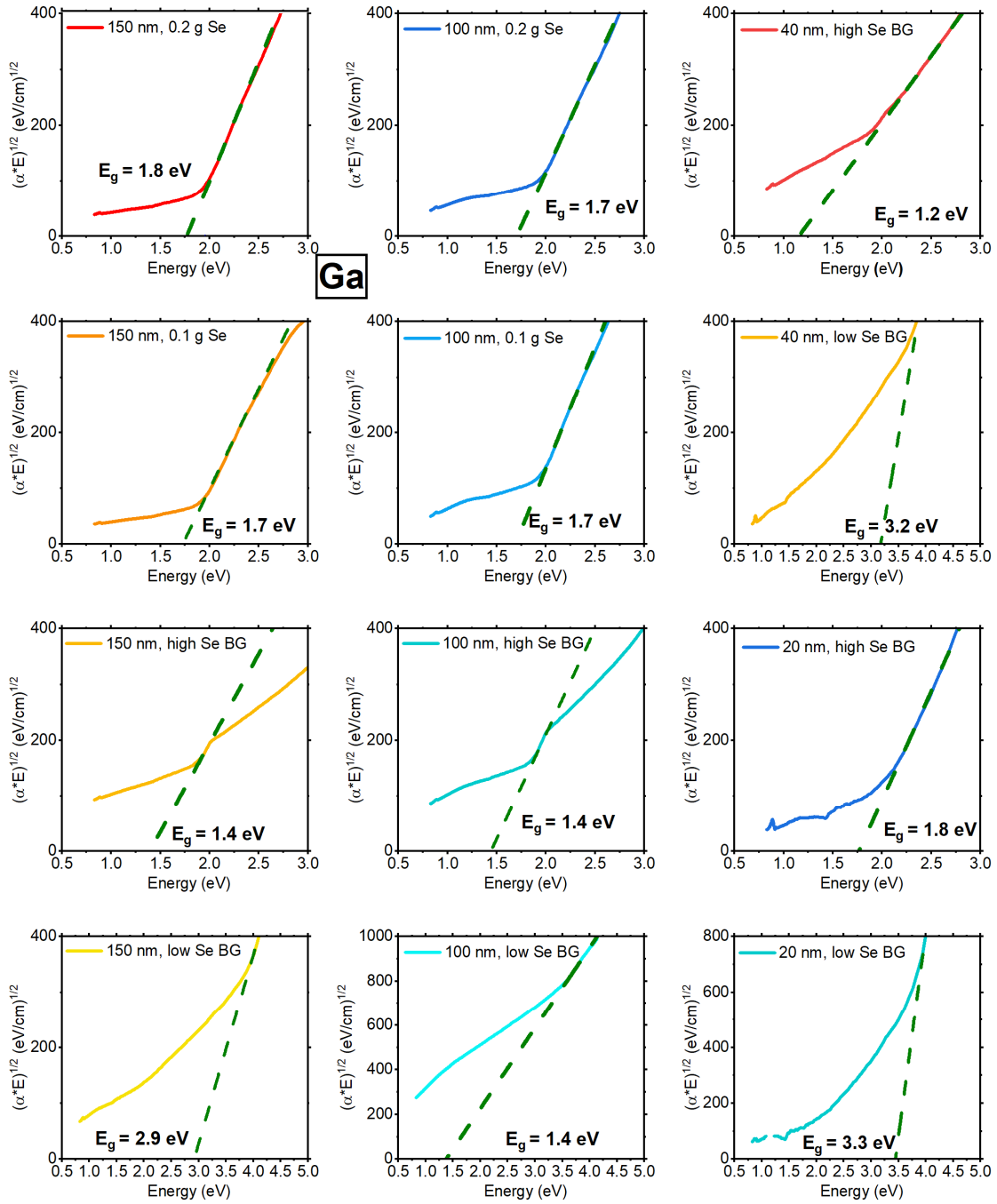


Figure S6: Tauc plot of $(\alpha E)^{1/2}$ for potential derivation of indirect band gap value from linear fitting; Ga-Se samples with 150, 100, 40 or 20 nm Ga precursor thickness and selenized in various Se content (BG = background).